

Notice of References Cited		Application/Control No.	Applicant(s)/Patent Under Reexamination VAARTSTRA ET AL.	
		Examiner Christy L. Novacek	Art Unit 2822	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6,017,818	01-2000	Lu, Jiong-Ping	438/653
	B	US-5,877,087	03-1999	Mosely et al.	438/656
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Ward et al., "New Developments in CVD Source Delivery and Source Reagents", Semiconductor Fabtech Journal, Edition 1, Section 5, Sept. 1994
	V	
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.